

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of

Taku HIRAYAMA et al.

Serial No. 10/568,951

Filed February 22, 2006

3 vg

Mail Stop: PCT Branch

Attorney Docket No. 2006_0227A

MATERIAL FOR FORMING RESIST PROTECTIVE FILM FOR LIQUID IMMERSION LITHOGRAPHY PROCESS, RESIST PROTECTIVE FILM FORMED BY THE MATERIAL, AND METHOD OF FORMING RESIST PATTERNS USING THE MATERIAL

REQUEST FOR CORRECTED FILING RECEIPT

Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

Sir:

Enclosed herewith is a copy of the Official Filing Receipt for the above-identified application marked with an arrow indicating corrections to be made thereto.

Accordingly, it is requested that the PTO issue a Corrected Filing Receipt reflecting these corrections.

Respectfully submitted,

Taku HIRAYAMA et al.

By.

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corrected



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UNITED STATES DEPARTMENT OF COMMERCE United States Patent and Trademark Office Address COMMISSIONEE FOR PATENTS FO. BEX 1450 Alexandria, Viginia 22313-1450

APPL NO. | FILING OR 371 | ART UNIT | FIL FEE REC'D | ATTY.DOCKET NO | DRAWINGS | TOT CLMS | IND CLMS | 10/568,951 | 05/05/2006 | 2851 | 1030 | 2006-0227A | 13 | 1

513
WENDEROTH, LIND & PONACK, L.L.P.
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SUITE 800
WASHINGTON, DC 20006-1021

CONFIRMATION NO. 9336

FILING RECEIPT
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Date Mailed: 10/31/2006

Receipt is acknowledged of this regular Patent Application. It will be considered in its order and you will be notified as to the results of the examination. Be sure to provide the U.S. APPLICATION NUMBER, FILING DATE, NAME OF APPLICANT, and TITLE OF INVENTION when inquiring about this application. Fees transmitted by check or draft are subject to collection. Please verify the accuracy of the data presented on this receipt. If an error is noted on this Filing Receipt, please mail to the Commissioner for Patents P.O. Box 1450 you received a "Notice to File Missing Parts" for this application, please submit any corrections to this Filing Receipt with your reply to the Notice. When the USPTO processes the reply to the Notice, the USPTO will generate another Filing Receipt incorporating the requested corrections (if appropriate).

Applicant(s)

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Assignment Four ublished Patent Application

TOKYO OHKA KOGYO CO., LTD., Kanagawa, JAPAN

Power of Attorney: The patent practitioners associated with Customer Number 513.

Domestic Priority data as claimed by applicant

This application is a 371 of PMT/JP04/12204 08/25/200

Foreign Applications

JAPAN 2003-300666 08/25/2003 JAPAN 2003-356963 10/16/2003

If Required, Foreign Filing License Granted: 10/2, 006

The country code and number of your priority application, to be used a filing abroad under the Parisi

Projected Publication Date: 02/08/2007



Non-Publication Request: No

Early Publication Request: No

Title

Material for forming resist-protecting film for immersion exposure process, resist-protecting film made of such material, and method for forming resist pattern using such resist-protecting film

Preliminary Class

355

PROTECTING YOUR INVENTION OUTSIDE THE UNITED STATE

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Almost every country has its own patent law, and a person desiring a patent in particular country must make an application for patent in that country in accordance with its particular laws. Since the laws of many countries different specific foreign countries to ensure that patent rights are not lost prematurely

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